Monolithic CIGS-Perovskite Tandem Cell for an Optimal Light Harvesting Without Current Matching

Paola Mantilla-Perez, Thomas Feurer, Juan-Pablo Correa-Baena, Quan Liu, Silvia Colodrero, Johann Toudert, Michael Saliba, Stephan Buecheler, Anders Hagfeldt, Ayodhya N. Tiwari and Jordi Martorell

1ICFO-Institut de Ciencies Fotoniques, The Barcelona Institute of Science and Technology, 08860 Castelldefels, Spain
2Laboratory for Thin Films and Photovoltaics, Empa-Swiss Federal Laboratories for Materials Science and Technology, Duebendorf, Switzerland.
3Laboratory for Photomolecular Science, Institute of Chemical Sciences and Engineering, Ecole Polytechnique Fédérale de Lausanne, Lausanne, Switzerland.
4Departament de Física, Universitat Politecnica de Catalunya, Terrassa, Spain

Keywords: Perovskite solar cells, CIGS solar cells, inverse integration, tandem, serial-parallel configuration.

Abstract

We present a novel monolithic architecture for optimal light harvesting in multi-junction thin film solar cells. In the configuration we consider, formed by a Perovskite (PVK) cell overlaying a CIGS cell, the current extracted from the two different junctions is de-coupled by the insertion of a dielectric non-periodic photonic multilayer structure. This photonic multilayer is designed by an inverse integration approach to confine the incident sun light above the PVK bandgap in the PVK absorber layer, while increasing the transparency for sun light below the PVK bandgap for an efficient coupling into the CIGS bottom cell. To match the maximum power point voltages in a parallel connection of the PVK and CIGS cells, the latter is divided into two sub-cells by means of a standard three laser scribing connection. Using realistic parameters for all the layers in the multi-junction architecture we predict power conversion efficiencies of 28%. This represents an improvement of 24% and 26% over the best CIGS and PVK single junction cells, respectively, while at the same time, outperforms the corresponding current matched standard tandem configuration by more than two percentage points.
Perovskites recently emerged as a solution processed PV technology which in a short period of time reached power conversion efficiencies (PCEs) comparable to the ones from the well-established lower bandgap crystalline Si technology \(^1\,^2\). One of the remarkable features of PVK cells is their high open circuit voltage (\(V_{oc}\)) which may reach values as high as 1.24 V (at a band gap of 1.63 eV) \(^3\). Such high voltages, a tuneable bandgap \(^4\) and a high charge mobility makes them an optimal technology to form a tandem with CIGS or crystalline Si based solar cells and lead to a low cost multi-junction technology suitable for terrestrial sun energy harvesting\(^5\,^10\). In the most standard tandem configuration the two cells are in a serial connection that requires current matching between both cells \(^11\,^14\). This constitutes a constraint in the optical design of the optimal tandem architecture which eventually limits the PCE of the final device. To partially circumvent such problems, 3-terminal \(^15\) or 4-terminal \(^6,^13,^16,^17\) configurations have been proposed. The former one is applicable when the two absorber materials are the same, while in the latter one, there are not material constraints. Mechanically stacked 4-terminal devices have shown efficiencies that overcome that of the corresponding single sub-cells, \(^6,^8\) but the monolithic character, which may be relevant to achieve a low cost solar module installation, would be lost to a large extent. A higher cost associated to the connectivity complexity is expected in the installation of such 4-T modules. On a theoretical basis it was proposed to connect an indefinite number of cells in series in each of the branches of a parallel configuration until the voltages of the two branches are matched.\(^18\) However, no practical implementation of the device configuration was considered. An alternative option proposed piling up three cells, two of them in a series connection and then these two connected in parallel with the remaining one.\(^19\) The latter combination is an interesting proposal to match the voltage but the problem of current matching remains.

In this work we propose a new configuration, denoted as S-P (serial-parallel), different than the standard or any other tandem scheme considered until now. We describe a monolithic tandem architecture where current matching between the PVK and CIGS cells is not required. Performing an optical optimization of the structure we predict an efficiency of 28% using a 1.56 eV bandgap PVK and PV parameters which have already been reached for the constituent CIGS or PVK sub-cells. Furthermore, we discuss the experimental viability of the proposed architecture.
Results and Discussion

As shown in Figure 1a, the configuration is formed with a semi-transparent PVK solar cell deposited on top of two CIGS solar cells laterally connected in series. A schematic drawing of the architecture with connection nodes numbered from 1 to 3 is shown in Figure 1b. Voltage-matching at nodes 1 and 3 from both branches of the circuit may, in principle, be achieved provided the maximum power point voltage ($V_{mpp}$) of the light-filtered CIGS cells is close to half the one from the PVK cell. The serial connection amongst the two CIGS cells can be implemented by means of laser scribing, a standard technique for the up-scaling of CIGS cells to modules. As seen in Figure 1a, a dielectric multilayer referred as 1-D photonic non-periodic dielectric structure (NDS) is inserted on top of the first CIGS solar cell serving the double purpose of avoiding short-circuiting of nodes 1 and 2 and maximizing light absorption for the first and second cell. On the other hand, the necessary current matching between the two serial connected CIGS devices can be easily obtained by defining an equal area for both.

In the implementation of the optical optimization described in Methods we consider a configuration where the CIGS solar cell architecture is the standard one and some changes are introduced to the PVK device, for instance, the use of top and bottom transparent conductive electrodes (TE). Specifically, the S-P architecture consists of the semi-transparent PVK cell on top of a CIGS cell separated by the NDS as follows: Glass/Mo/MoSe/CIGS/CdS/i-ZnO/AZO/ Low-n film/High-n film/ Low-n film/TE/PEDOT:PSS/PVK/PCBM/ TE/MgF$_2$. As TEs for the semi-transparent PVK we considered 90 nm ITO films. The ITO is chosen instead of the common FTO due to its better processing compatibility with the underlying materials and its improved near infrared transmission. Similar thickness of ITO films, prepared at room temperature, have been employed to form a recombination layer and top contact in a monolithic tandem architecture with PVK and Silicon, exhibiting high fill factors.

In the S-P configuration considered in here, the optical optimization is performed for a device that includes the NDS between the inner TE/AZO interface as seen in Fig. 1a. Such NDS is formed by a combination of three layers of intercalated low and high refractive index materials and has a two-fold functionality. Firstly, it electrically separates the TE anode of the PVK and the AZO cathode of the CIGS and secondly, it confines the incident sun light above the PVK bandgap in the PVK absorber.
layer, while increasing the transparency for sun light below the PVK bandgap for an efficient coupling into the CIGS bottom cell. To prevent tunnelling from electrical charges between the PVK and CIGS cells one may use MgF₂ as low n material, which is a highly insulating transparent material exhibiting a refractive index close to 1.38. For the high n film, a highly transparent dielectric material with a refractive index of 2.2 would be the optimal. Possible materials for the high index layer may be TiO₂ or Si₃N₄. Considering the three films, the total thickness of the NDS would be above 500 nm, sufficient, in principle, to prevent electrical charge tunnelling. When the inverse integration optical optimization detailed in the Methods section is applied, the EQEs obtained for the NDS separated PVK and CIGS cells are shown in Fig. 2a. Under the assumption of a negligible extinction coefficient for any of the layers within the NDS, we observe an enhancement in the maximum short-circuit current of the PVK and CIGS sub-cells, especially in the wavelength range between 700 and 900 nm. The NDS fine tuning required to reach maximum PCE may be extracted from Fig. 2b where the transmission at 5 different wavelengths just above and below the PVK bandgap is shown as a function of the NDS low refractive index material. In such Figure one observes that for the cell architecture with the highest short-circuit current sum, when the NDS low index material is close to 1.38, the inverse integration leads to an NDS transmission larger at longer wavelengths to favour absorption at the CIGS and smaller at shorter wavelengths to favour absorption in the PVK. Note that the unbalanced current density in both sub-cells explains why the PCE of the S-P configuration is considerably larger than the PCE for the current matched tandem, as seen in Figure 3a. The optimal thicknesses for the critical layers inside the S-P structure depend on the selected TE. When using a 90 nm ITO the optimal architecture is: Glass/Mo/MoSe/CIGS (2.5µm)/CdS (40nm)/i-ZnO(50nm)/AZO(100nm)/ Low-n film(70nm)/High-n film(220nm)/ Low-n film(250nm)/ITO (90 nm) /PEDOT:PSS (20nm)/PVK(700nm)/PCBM(20nm)/ITO (90nm) /MgF₂(98nm), delivering a $J_{sc}$ of 22.06 mA/cm² for the PVK and 14.1 mA/cm² for the CIGS.

To confirm that such increase in photocurrent in the S-P configuration corresponds to an equivalent increase in PCE, we determined the rest of the electrical parameters that characterize the overall IV curves employing the single diode electrical equivalent circuit model. The single diode circuit model was applied to each branch of the circuit and then the currents were added point by point to obtain the
resulting IV curve. To reach optimal PCEs we set the FF between 80% and 81% for all the single junction cells used in the S-P configuration. A similar procedure was used to determine the optimal configuration for a standard current matched tandem, which is used as a reference for comparison. Although small variations resulting from the IV curves fitting may be found, the FF of the S-P structure closely approached that of the sub-cell with the highest FF for most of the cases considered. On the other hand, the $V_{oc}$ of the S-P is roughly limited by the voltage of the branch that has the lowest voltage, as can be seen in Fig. S1 of the SI. We studied two cases, one where the $V_{oc}$ of the PVK was fixed to 1180 mV while the $V_{oc}$ of the CIGS was varied in the 600-700 mV range, and a second case where the $V_{oc}$ of the CIGS was fixed to 660 mV and the one of the PVK was allowed to change in the 1080-1240 mV range. The ideality factor, series resistance, shunt resistance, and saturation current were determined to match experimental curves when available (Fig. S2 of the SI) or from the computer generated single junction IV curves exhibiting the targeted $J_{sc}$, FF and $V_{oc}$ parameters. Note that the changes in $V_{oc}$ considered in here are not associated to bandgap modifications which will be considered below. Indeed the $V_{oc}$ ranges encompass a wide variety of voltages that are often found in experimental CIGS or PVK single junction devices.

As seen in Figure 3a, when a PVK cell with a $V_{oc}$ of 1180 mV is combined with a CIGS cell in the S-P configuration, the efficiency remains more less around the 28% as the $V_{oc}$ of the CIGS changes. This PCE is clearly larger than the PCE from any of the possible tandem configurations also shown in Figure 3a. In the event that the $V_{oc}$ of the PVK is further increased, PCEs above 29% would be reachable while for the standard tandem configuration PCEs larger than 27% are, in principle, not possible. This confirms that the S-P configuration clearly outperforms the standard tandem by more than two percentage points in almost all cases. Note that, when optimal single junction cells are considered, both configurations tandem and S-P, will clearly outperform record PCEs for CIGS $^{20}$ and PVK$^{21}$ single junction cells.

Provided that in the S-P configuration no current matching is required between the PVK and the CIGS cells, a further increase in the PCE may be achieved by tuning the bandgap of either the PVK or CIGS cells. For PVK cells several authors have considered tuning the bandgap by changing the relative halide composition and observed an increase in the $V_{oc}$. Although in most cases studied no clear relationship...
was established between the $V_{oc}$ and the bandgap, from the wide bandgap tuning study reported by Noh et al. 4 one may extract a close to linear correspondence between these two parameters when the bandgap is changed from 1.57 eV to 2.29 eV. The $V_{oc}$ values therein reported are, however, low in comparison to recent reports. For instance, PVK cells with a measured bandgap of 1.56 eV have reached a $V_{oc}$ as high as 1.19 V 22. Similarly, for a higher bandgap PVK of 1.62 eV, a $V_{oc}$ of 1.24 eV 3 was recently achieved which corresponds to a loss-in-potential (difference bandgap and $V_{oc}$) of 0.39 eV which is close to the thermodynamic limit. Thus, an increase in $V_{oc}$ may be achievable for the other bandgaps as well once the charge extraction contacts and the perovskite composition have been optimized to overcome limiting effects such as the one described in Ref [23]. For this work, the above two values are taken as references and used to establish a linear relation between the $V_{oc}$ and the bandgap in the range of 1.51 eV to 1.71 eV, shown in Figure 3b. At present, there are material compositions for PVK cells yielding bandgaps below 1.56 eV 13, 24, 25. However, such compositions have led to suboptimal devices which were not taken as references for this analysis. A monotonic decrease of the total calculated short-circuit current density as the bandgap increases is observed in Figure 4a. Note that we have plotted the sum of the short-circuit current density of the PVK with half of the CIGS to account for the differences in area inherent to the S-P structure. When estimating the PCE using the same single diode model described above one observes, as can be seen in Fig. 4a, an increase in PCE as the band gap of the PVK increases. Although this may seem counter-intuitive provided the bandgap of PVK is well above the optimal single junction solar cell bandgap, the explanation is that the bandgap increase implies a better voltage matching with the CIGS branch of the circuit.

**Methods**

**Intercalated non-periodic photonic structure for an optimal light harvesting**

To design the specific architecture for the S-P cell, we set the sum of the photocurrents as the target optimization parameter within our numerical calculations.

From Figure 1b, it can be seen that the maximum electrical power $P$ derived from the device is given by:

$$P = (I_{CIGS} + I_{PVK}) \times V_p \times FF \quad (Eq. 1)$$
where $I_{CIGS}$ is the short-circuit current generated by the CIGS solar cell and $I_{PVK}$ is the short-circuit current generated by the PVK. $V_p$ and $FF$ are the corresponding voltage and fill factor from the parallel connection.

$$I_{PVK} = J_{PVK} \times (A_T) \quad \text{(Eq. 2)}$$

being $J_{PVK}$ the short-circuit current density from the PVK and $A_T$ the total illumination area of the device. Neglecting the dead area, $A_T$ corresponds to:

$$A_T = A_1 + A_2 \quad \text{(Eq. 3)}$$

where $A_1$ and $A_2$ are the areas for the CIGS sub-cells (for practical considerations refer to the next subsection). The current flowing through the CIGS cells must fulfil:

$$I_{CIGS} = A_1 \times J_{CIGS_1} = A_2 \times J_{CIGS_2}. \quad \text{(Eq. 4)}$$

By simple algebra one may write the PCE as:

$$PCE = \frac{[A_1 \times J_{CIGS_1} + (A_T \times J_{PVK})] \times V_p \times FF}{P_{AML5} \times A_T} \quad \text{(Eq. 5)}$$

We determine the optimal cell architecture by implementing an inverse integration approach where the photocurrent from each one of a large set of possible configuration solutions is numerically computed using a transfer matrix formalism. Configurations are defined by a large set of different input parameters, including thicknesses and/or optical constants for some or all the device layers which are allowed to vary within a specified range. The target solution is selected from that set of all possible solutions.

When implementing the transfer matrix model, it is assumed that:

All layers are considered homogeneous and isotropic, such that their optical characteristics can be represented by scalar complex indexes of refraction; interfaces between adjacent layers are parallel and optically flat; incident light is perpendicular to the stack and can be described by plane waves; the efficiencies in exciton diffusion, charge separation, and carrier transport and collection are wavelength independent. To perform these calculations one must know the complex index of refraction and thickness for each layer in the architecture. The refractive indexes for each layer were taken from references [26, 27] for the CIGS solar cell and from references [28, 29] for most of the layers in the PVK solar cell.
Using the calculated optical electrical field intensities for the CIGS and PVK, together with their optical properties, the absorption is computed to finally determine the short-circuit current density ($J_{sc}$) for each sub-cell. $J_{sc}$'s for the PVK and CIGS cells were computed for 10,000 different combinations of layer thicknesses when varying the absorber layers, the entrance transparent electrode, and the intermediate dielectric NDS layers. The thickness ranges were in accordance with the experimental constraints to obtain optimal FF or $V_{oc}$ for both cells. We assumed an internal quantum efficiency (IQE) of 100% for the PVK cell as demonstrated in Refs. [30, 31] and 92% for the CIGS solar cells 32. In the PCE estimates, we obtained the equivalent parallel voltage $V_p$ and FF by adding the IV curves corresponding to each one of the branches of the circuit.

Experimental implementation of S-P structure

The CIGS bottom cells in this design can be deposited in the different ways described in literature, since there are no special limitations on process temperature or conditions present at this point. In order to reach the desired efficiency a deposition by co-evaporation or precursor selenization seems to be favourable. The substrate can be rigid (soda lime glass) or flexible (polyimides, steel), especially in view of possible roll-to-roll production. Back contact is typically Mo around 500 nm. The absorber will be between 2 and 3 µm thick, followed by a buffer layer (most likely CdS by chemical bath deposition) and a multilayer of intrinsic and doped Zinc oxide as TE. The front contact sheet resistance should be below 10 Ohm/sq for a monolithic cell interconnection.

Concerning the fabrication of the PVK device on top of the CIGS, a number of constraints are introduced to prevent damage of the bottom CIGS layer. For instance, thermal instability has been observed for the n-type buffer layer in CIGS solar cells, where atoms tend to diffuse from the buffer to the absorber layer significantly reducing the performance of the device by an augmented recombination. Temperatures above 300ºC trigger this process and have been shown to be detrimental to all PV parameters of CIGS solar cells 33. Therefore, annealing processes used to manufacture all the layers within the PVK device are temperature-limited, which excludes the use of frequent configurations like
the mesoscopic PVK on 500ºC sintered TiO2. The PVK layer itself does not require high temperature annealing and neither does the PCBM. On the other hand, ITO has been shown to provide good quality transparent electrodes at the bottom or the top of PVKs solar cells. Connection of PVK cells to modules has been reported in the literature, some with a reduced area loss of 3% of the total 16 cm² module area.

Similarly to the case of PVK, for the lateral serial connection of the CIGS solar cells three structured patterns denominated P1, P2 and P3 are required, as seen in Figure 1a. The first pattern P1 and the third pattern P3 separate the positive and negative contacts of adjacent cells, respectively. The second pattern P2 allows the negative contact of one cell to be connected with the positive contact of the following cell. The region in between P1 and P3, including both, is the dead area (DA). Typically, laser scribing is employed to define such patterns. If we assume that the dead area corresponds to a fraction X of the total CIGS active cell area, then:

\[ DA = X \times (A_1 + A_2), \]  (Eq. 6)

Within the optically optimized S-P structure we consider the effect of the DA in the total PCE by normalizing it without neglecting the DA. As can be seen in Figure 4b, under the assumption of a cell larger than 1 cm, the effective loss in PCE is less than 2% even when the separation between P1 and P3, including the width of such laser cuts, is as large as 500 µm. For separations as small as 100 µm, which have been recently outperformed in the series connection of CIGS cells, the loss in PCE is negligible.

**Conclusions**

In summary, we proposed and studied a new tandem configuration were the constraint of current density matching is removed. Two CIGS cells laterally connected in series may be connected in parallel with a PVK cell matching the maximum power point voltages. The configuration studied is monolithic but the currents from the top PVK and the bottom CIGS cells can be extracted separately. We demonstrated that when the two cells are electrically separated by a dielectric non-periodic photonic multilayer structure, such photonic structure can be designed to effectively confine the incident sun light above the PVK bandgap in the PVK absorber layer. The same photonic structure is used to reach an optimal
transparency for sunlight below such bandgap and efficiently couple it into the CIGS bottom cell. Using realistic current state of the art parameters for all layers in the multi-junction architecture we estimated that PCEs above 28% can be achieved. The PCE of the S-P configuration is for most of the cases studied two percentage points higher in efficiency than the estimated for an optimal series connected standard tandem configuration or the 22.6% and 22.1% which are the maximum efficiencies reported for CIGS and PVK single junction cells, respectively. Any improvement in the sub-cells will further increase the potential efficiency of the S-P cell. For a successful experimental implementation of the S-P configuration, the procedures to fabricate high quality semi-transparent electrodes with the limitations imposed by the layers already deposited must be improved. In addition, the optical optimization of the NDS must be made compatible with its role of preventing short-circuiting between the two sub-cells.

Supporting Information

Curve of equivalent $V_{oc}$ for the S-P configuration when varying the $V_{oc}$ of the PVK subcell or $V_{oc}$ of the CIGS subcell. Fitting data of IV curves. Module interconnection schemes for the S-P configuration.

Acknowledgments

P.M.P, Q.L, S.C, J.T. and J.M acknowledge financial support from the Spanish MINECO (Severo Ochoa program, grant No.: SEV-2015-0522), the MINECO, the Fondo Europeo de Desarrollo Regional FEDER (grant No.: MAT2014-52985-R), the Fundació Privada Cellex, the CERCA programme from the Generalitat de Catalunya. M.S. acknowledges support from the co-funded Marie Skłodowska Curie fellowship, H2020 Grant agreement no. 665667. Financial funding from the Swiss National Science Foundation (SNF)-NanoTera as well as Competence Center for Energy and Mobility (CCEM Connect-PV) is gratefully acknowledged.
Figures

Figure 1. (a) Schematic drawing of the monolithic multi-junction device composed of a two series connected CIGS cells connected in parallel with a PVK cell. (b) Schematic drawing of the connections of the S-P configuration.

Figure 2. (a) Calculated EQE for the Perovskite (black) and the CIGS (red) sub-cells for the optimal configuration. (b) Sum of PVK and CIGS photocurrents densities (black squares) and transmission of the NDS at 700 nm (black line), 710 nm (red), 824 nm (blue dash), 852 nm (magenta dash dot), and 884 nm (green dash dot dot) as a function of the refractive index of the low-n NDS layer.
Figure 3. (a) PCEs for the tandem (dashed lines) and S-P (continuous lines) configurations. The red lines correspond to a fixed $V_{oc}$ for the CIGS solar cells at 660 mV while the $V_{oc}$ of the PVK is allowed to change from 1080 to 1240 mV. The blue lines correspond to a fixed $V_{oc}$ condition of the PVK at 1180 mV while the $V_{oc}$ of the CIGS is allowed to change from 600 to 690 mV. (b) Estimate of PVK $V_{oc}$ as a function of the PVK bandgap. The two reference values are marked as vertical lines.

Figure 4. (a) PCE of the CIGS/PVK S-P cells as a function of the PVK bandgap (squares) and sum of PVK and CIGS halved short-circuit current densities for the S-P configuration as a function of the PVK
bandgap (line). (b) PCE as a function of DA width of the serial connected cells assuming devices with an area of 12x12 mm².

References


